

Joint International Conference on The 8th ICMAP & The 9th ISFM

January 17-20, 2021 | Online Conference

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|---|---------------------------------------|
| [WB2] Plasma Diagnostics and Process Monitoring Technology III | |
| Date / Time | January 20 (Wed.), 2021 / 11:00-12:20 |
| Place | Channel B |
| Session Chair(s) | Duk Sun Han (KFE, Korea) |

[WB2-1] Invited

11:00-11:30

Tomography-Based Optical Diagnostics for Real-Time Monitoring of Spatial Uniformity in Microelectronics Processing Plasmas

Wonho Choe

KAIST, Korea

[WB2-2]

11:30-11:50

Improvement of Triple Probe Measurement on Non-Maxwellian Plasmas

Namjae Bae, Jaemin Song, Jihoon Park, Haneul Lee, and Gon-Ho Kim

Seoul Nat'l Univ., Korea

[WB2-3] Invited

11:50-12:20

Predictive Control of the Plasma Processes after Discontinuities in the OLED Display Mass Production Line Referring to the PI-VM Model

Seolhye Park¹, Jaegu Seong¹, Yeongil Noh¹, Yoona Park¹, Yongsuk Jang¹, Taeyoung Cho¹, Jae Ho Yang¹, and Gon-Ho Kim²

¹Samsung Display Co., Ltd., Korea, ²Seoul Nat'l Univ., Korea